Translation

PATENT COOPERATION TREATY

PCT

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

(Chapter II of the Patent Cooperation Treaty)

(PCT Article 36 and Rule 70)

Applicar	nt's or ag	ent's file refe	erence				
NEC04P012				FOR FURTHER A	ACTION	See Form PCT/IPEA/416	
International application No.				International filing d	ate (day/month/year)	Priority date (day/month/year)	
PCT	/JP2	004/00	05997	26.04.200	4	20.06.2003	
International Patent Classification (IPC) or national classification and IPC					I		
l							
Applicat	nt						
NEC	COR	PORAT	ION				
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1.	 This report is the international preliminary examination report, established by this International Preliminary Examining Authority under Article 35 and transmitted to the applicant according to Article 36. 						
2.	This R	EPORT cons	sists of a total of	5	sheets, including	g this cover sheet.	
3.	This re	port is also a	ccompanied by Al	NEXES, comprising	:		
	a. 🗵) (sant to	the applicant and	to the International B		shorts on full sure	
	a. k	- (· · · —	sheets, as follows:	
į	sheets of the description, claims and/or drawings which have been amended and are the basis for this report and/or sheets containing rectifications authorized by this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions).						
						siders contain an amendment that goes beyond	
			e disclosure in the ox.	international applica	tion as filed, as indicated	in item 4 of Box No. I and the Supplemental	
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		1 . 1 . 1		111.6		, containing a sequence listing and/or tables	
				readable form only, a rative Instructions).	as indicated in the Supplei	mental Box Relating to Sequence Listing (see	
4.		port contains	indications relatir	ng to the following ite	ms:		
	\boxtimes	Box No. I	Basis of the	report			
		Box No. II	Priority				
	\boxtimes	Box No. III	Non-establis	hment of opinion witl	n regard to novelty, inventi	ive step and industrial applicability	
		Box No. IV	Lack of unit	y of invention			
	\boxtimes	Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement					
		Box No. VI	Certain docu	iments cited			
		Box No. VI	I Certain defe	Certain defects in the international application			
	Box No. VIII Certain observations on the international application						
Date of	submissi	on of the der	nand		Date of completion of thi	s report	
			-		or complement of the		
Name and mailing address of the IPEA/JP				Authorized officer			
maining access of the ALLEVIL					-		
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Box	k No. I	Basis of the report					
1.		ed to the language, this report is based on the internation	nal application in the language in	which it was filed, unless otherwise			
	This report is based on translations from the original language into the following						
	which is the language of a translation furnished for the purposes of:						
	international search (Rule 12.3 and 23.1(b)) publication of the international application (Rule 12.4)						
		international preliminary examination (Rule 55.2 and					
2.	receiving (this report	nternational application as originally filed/furnished					
		description:					
	page			as originally filed/furnished			
	page						
	page .	•	received by this Authority on				
		claims:					
	nos.	4-13,16-20		as originally filed/furnished			
	nos.*		-	er with any statement) under Article 19			
	nos.*		received by this Authority on	02.03.2005			
	nos.*	*	received by this Authority on				
	the d	trawings:					
	sheet	ts <u>1-11</u>		as originally filed/furnished			
	sheet						
	sheet	ts*	received by this Authority on				
	∐ a seq	quence listing and/or any related table(s) - see Supplem	nental Box Relating to Sequence L	isting.			
3.	The The	amendments have resulted in the cancellation of:					
		the description, pages					
	\bowtie	the claims, nos. 14,15					
	\sqcup	the drawings, sheets/figs					
		the sequence listing (specify):					
		any table(s) related to sequence listing (specify):					
4.		report has been established as if (some of) the amend have been considered to go beyond the disclosure as fi					
		the description, pages					
		the claims, nos.					
		the drawings, sheets/figs					
		the sequence listing (specify):	·				
	any table(s) related to sequence listing (specify):						
<u>+</u>	If item 4 a	pplies, some or all of those sheets may be marked "sup	erseded."				

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Box No. III	Non-establishment of opinion	with regard to novelty, inventive step and industrial app	plicability
	ns whether the claimed invention appave not been examined in respect of:	pears to be novel, to involve an inventive step (to be no	n obvious), or to be industrially
	he entire international application		
\boxtimes	claims Nos. 4-8, 18-21, 25-32		
because	:		
, D	the said international application, or the	said claims Nos.	
1	relate to the following subject matter w	hich does not require an international preliminary examination	on (specify):
			,
	the description, claims or drawings (inc are so unclear that no meaningful opini	ticate particular elements below) or said claims Nos on could be formed (specify):	
	the claims, or said claims Nos.		are so inadequately supported
	by the description that no meaningful of	opinion could be formed.	
	no international search report has been	established for said claims Nos. 4-8,18-21,25-32	
	the nucleotide and/or amino acid seque Instructions in that:	ence listing does not comply with the standard provided for	in Annex C of the Administrative
	the written form	has not been furnished	
		does not comply with the standard	
	the computer readable form	has not been furnished	
	Sie Jourpuler readante totul	does not comply with the standard	
		d/or amino acid sequence listing, if in computer readable f Annex C-bis of the Administrative Instructions.	form only, do not comply with the
	See Supplemental Box for further deta	_	

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Box	x No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement	
1.	Statement	
	Novelty (N) Claims 1-3, 9-13, 16, 17, 22-24	_ YES
	Claims	_ NO
	Inventive step (IS) Claims	_ YES
	Claims 1-3, 9-13, 16, 17, 22-24	_ NO
	Industrial applicability (IA) Claims 1-3, 9-13, 16, 17, 22-24	_ YES
	Claims	_ NO
2.	Citations and explanations (Rule 70.7)	
	Document 1: JP 9-162402 A (Ricoh Co., Ltd.), 20 June 1997	
	Document 2: JP 11-289088 A (Matsushita Electronics	
	Industry Corporation), 19 October 1999	
	Document 3: JP 2002-231717 A (Texas Instruments, Inc.),	
	16 August 2002	
	Document 4: JP 10-303141 A (Sony Corporation), 13	
	November 1998	
	Document 5: JP 2002-368211 A (Toshiba Corporation), 20	
	December 2002, entire text; all drawings	
	(Family: none)	
	Document 6: JP 2003-37115 A (NEC Corporation), 7 February	
	2003, entire text; all drawings & US 2003/0022426 A1 & KR 2003010507 A & TW	
	548703 A	
	Document 7: JP 3-74878 A (Hitachi, Ltd.), 29 March 1991	
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	Claims 1 to 3, 9 to 13, 16, 17 and 22 to 24	
	The inventions set forth in claims 1 to 3, 9 to 13,	
	16, 17 and 22 to 24 do not involve an inventive step in	
	the light of documents 1 to 6.	
	Document 3 sets forth a metal oxide film with a high	
	dielectric constant provided as a gate insulating film	
	via a silicon-containing insulating film, therefore it	

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Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

would be easy for a person skilled in the art to apply the gate insulating film disclosed in document 3 as the gate insulating film in the invention set forth in document 1 (entire text; all drawings) and document 2 (paragraphs [0036] to [0058], [0080]; fig. 1, 2 and 6).

In addition, documents 4 to 6 set forth a feature wherein a sidewall comprising a silicon oxide film is formed via an insulating film comprising a silicon oxide film in order to prevent the occurrence of stress, and to prevent the occurrence of boundary levels by ensuring that a sidewall comprising a silicon nitride film does not come into direct contact with a semiconductor substrate. It would therefore be easy for a person skilled in the art to employ the feature of forming a silicon oxide film set forth in documents 4 to 6 before forming the silicon nitride film of the inventions set forth in documents 1 and 2.

Moreover, it was a known technique at the time of filing of this application to form an insulating film comprising a silicon nitride film on a metal oxide film with a high dielectric constant in order to prevent reactions between the metal oxide film with a high dielectric constant and the gate electrode.